

# Creating perfect coatings, atom by atom, at 600 m<sup>2</sup>/h

Kalpana Systems' K300 is the first R2R spatial Atomic Layer Deposition system available for industrial throughput and inline deposition.

- **Endless possibilities**

Large variety of materials, defect free, conformal, highly controllable deposition

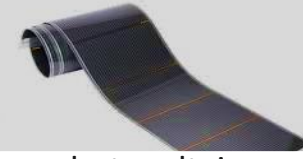
- **Compatible with Industry**

High throughput, high uptime, easy maintenance, low Cost of Ownership

- **Sustainable**

Low temperatures process, no vacuum, efficient precursor use.

## Thin films are everywhere!



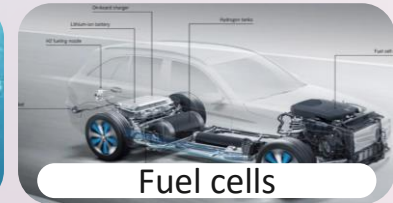
photovoltaics



batteries



electrolysis



Fuel cells



packaging



Capacitors



Super conductors



packaging